



SDI Review Form 1.6

Journal Name:	International Research Journal of Pure and Applied Chemistry
Manuscript Number:	2014_IRJPAC_11187
Title of the Manuscript:	Electronic Transport at Low temperature in Ni/Al/Ni Films
Type of the Article	

General guideline for Peer Review process:

This journal's peer review policy states that **NO** manuscript should be rejected only on the basis of '**lack of Novelty**', provided the manuscript is scientifically robust and technically sound.

To know the complete guideline for Peer Review process, reviewers are requested to visit this link:

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PART 1: Review Comments

	Reviewer's comment	Author's comment (if agreed with reviewer, correct the manuscript and highlight that part in the manuscript. It is mandatory that authors should write his/her feedback here)
<u>Compulsory</u> REVISION comments		
<u>Minor</u> REVISION comments	This paper well investigated the characteristics of sandwich Ni(100nm)/Al(t)/Ni(100nm) films. Before the paper is accepted, two problems should be improved. 1. Some typed errors in this paper should be edited, for example, "t =10 nm to10 nm were", and more. 2. Authors should give more detailed description for Fig.6, why the NAN6 has the smaller resistivity.	Typo graphical mistakes such as t=10 nm to 10 nm etc are now corrected and they are written in red font. Resistivity of NAN6 is smaller than NAN2, NAN8, NAN9 and NAN10 films. Also its TCR value was higher than other five films. The reasons for higher TCR and smaller resistivity of NAN6 than other films have not been completely understood yet. Now we have mentioned about this in the paper. Grammar corrections are done to the large extent. Redundancies are removed.
<u>Optional/General</u> comments	Yes, this paper is ethical.	